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# THE REACTIONS OF ORGANOMETALLIC COMPOUNDS INVOLVING SILICON

## Reactions of Triphenyl-, Diphenylmethyl-, and Phenyldimethylsilyl potassium with Fluorene in Tetrahydrofuran

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Triphenylsilylpotassium (Ph<sub>3</sub>SiK), diphenlylmethylsilylpotassium (Ph<sub>2</sub>MeSiK), and phenyldimethylsilylpotassium (PhMe<sub>2</sub>SiK) react very rapidly with fluorene in tetrahydrofuran (THF). The reactions can be followed at low temperatures using a stop-flow technique. The thermodynamic constants of activation was calculated for the reactions of organosilylpotassium (R<sub>3</sub>SiK) with fluorene for  $-50^{\circ}$ . The results were compared with the corresponding reactions of organosilyllithium (R<sub>3</sub>SiLi), and organosilylsodium (R<sub>3</sub>SiNa) with fluorene, also calculated for  $-50^{\circ}$ . The bimolecular rate constant k increases with the increase in radius of cation. The sequence for the  $\Delta H^{\ddagger}$  and  $\Delta S^{\ddagger}$  values, R<sub>3</sub>SiNa  $\angle$ R<sub>3</sub>SiK  $\angle$ R<sub>3</sub>SiLi, parallels that for the A factor. The electronic spectra of R<sub>3</sub>SiK and 9-fluorenylpotassium were determined at temperature varying from +20 to  $-80^{\circ}$ . The special results are in full agreement with the kinetic results, that R<sub>3</sub>SiK compounds exist as contact ion pairs in THF and the cation plays an important role in determining the rate of these reactions.

### INTRODUCTION

The reactions of substituted silvllithium and silvlsodium with fluorene [1,2] in THF have been investigated. It was observed that the biomolecular rate constant k was higher in the case of R<sub>3</sub>SiNa, compared with the corresponding reactions of R<sub>3</sub>SiLi. The relative reactivity of R<sub>3</sub>SiLi and R<sub>3</sub>SiNa have been discussed in terms of the degree of solvation attained by these reagents in the initial and the transition states. The reactions of R<sub>3</sub>SiK with fluorene in THF are now investigated and the results are presented in this paper.

#### EXPERIMENTAL

*Materials*. Fluorene [3], tetrahydrofuran [4] and hexaphenyldisilane [5] were purified and dried as described in the previous papers. 1,1',2,2'-tetraphenyl-1,2-dimethyldisilane and 1,2-diphenyl-1,1'2,2'- tetramethyldisilane were prepared by the reaction of sodium with the respective chlorosilane as described by Gilman *et al.* [6] and purified as described earlier [5]. Ph<sub>3</sub>SiK, Ph<sub>2</sub>MeSik and PhMe<sub>2</sub> SiK were prepared by the cleavage of the corresponding symmetrical disilanes with potassium in THF using a method similar to that described for the organosilyl-lithium compounds [7].

Spectral Measurement. The electronic spectra of  $R_3SiK$  and 9-fluorenylpotassium were determined at temperatures varying from 20 to  $-80^\circ$  using the same technique as described for 9-phenylfluoren-9-yl-lithium in the previous papers [5].

Kinetic Measurements. The reactions of  $R_3SiK$  with fluorene in THF were studied using the stopflow technique, by following the changes in optical density with time at 470 nm which is one of the absorption peaks of the product, 9-fluorenylpotassium. The order of reaction in  $R_3SiK$  and fluorene was determined using a procedure similar to that described for the reactions of organosilyllithiums with 9-phenylfluorene [5].

#### RESULTS

Spectra. The spectra of  $R_3SiK$  determined at 20° are shown in Fig. 1. The position of maximum absorption is 363 nm for both Ph<sub>3</sub>SiK ( $\epsilon\lambda$  max 1.28× 10<sup>4</sup>) and Ph<sub>2</sub>MeSiK ( $\epsilon\lambda$  max 1.06×10<sup>4</sup>) with shoulders at 262 and 255 nm respectivley. The spectrum of PhMe<sub>2</sub>SiK is very broad and it is difficult to locate the absorption maximum in this case, the principal absorption maxium is, however, designated at 340 nm ( $\epsilon\lambda$  max 7.6×10<sup>3</sup>) with a shoulder at 275 nm. The positions of abosrption maxima and the values of extinction coefficients for these spectra do not change as the temperature is reduced to -80°.

The product of the reaction between R<sub>3</sub>SiK and fluorene in THF, 9-fluorenylpotassium gave a sepectrum with absorption maxima at 470 ( $\epsilon\lambda$  max 1.5×10<sup>3</sup>) and 500 nm ( $\epsilon\lambda$  max. 1.08×10<sup>3</sup>) and a shoulder at 520 nm. The spectrum of 9-fluorenylpotassium also remained unaltered at reduced temperatures.

Kinetics The rates of reaction of  $R_3SiK$  with fluorene in THF were measured at  $-50^{\circ}C$  to investigate the order of reaction. The order of reaction found from the dependence of initial rate on initial reactant concentration was  $1.01\pm0.02$  for  $R_3SiK$ , and  $1.01\pm0.03$  for fluorene (Tables 1 and 2). The overall order of reaction found on the analysis of the optical density vs. time curve was 2 for at least 90% of the reaction (Fig. 2). The  $R_3SiK$ reactions with fluorene in THF may be considered as irreversible under the experimental conditions used.

The activation energy and the A factor were determined from the change in rate constant of reaction over the temperature range of -8 to  $-57^{\circ}$ C. (Table 3.) The values found for the activation energy

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	103[Fluorene]i	103[R3SiK]i	k	
	mole 1-1	mole1-1	mole-1 sec-1	
Ph <sub>3</sub> SiK	4.21	3.82	10.8	
	4.21	6.53	11.0	
	4.21	9.75	11.1	
	4.21	12.91	11.0	
Ph2MeSiK	3.12	1.82	35.5	
	3.12	2.76	36.4	
	3.12	4.16	36.0	
	3.12	6.21	36.4	
PhMe <sub>2</sub> SiK	3.06	2.15	32.5	
	3.06	3.65	32.1	
	3.06	4.78	33.0	
	3.06	6.22	32.5	
69.8	In In	itial rate		
	$k = \frac{1}{[R_3SiK]}$	]i [Fluorene]i		





Fig. 2. The second order plots of the reactions between organosilylpotassiums and fluorene in THF at  $-50^{\circ}$ .  $A=Ph_3SiK$ fluorene system:  $[Ph_3SiK]_i = 7\cdot28 \times 10^{-3}$  M,  $[Fluorene]_i$  $=4\cdot63\times10^{-3}$  M,  $k=10\cdot31$  mole<sup>-1</sup> sec<sup>-1</sup>;  $B=Ph_2MeSiK$ fluorene system:  $[Ph_2MeSiK]_i = 5\cdot12\times10^{-3}$  M,  $[Fluorene]_i$  $3\cdot54\times10^{-3}$  M,  $k=36\cdot41$  mole<sup>-1</sup> sec<sup>-1</sup>, and  $C=PhMe_2$ SiK-fluorene system:  $[PhMe_2SiK]_i = 6\cdot57\times10^{-3}$  M, [Fluo $rene]_i = 3\cdot42\times10^{-3}$  M,  $k=33\cdot21$ . mole<sup>-1</sup> sec<sup>-1</sup>.

Table 2. Reaction data in THF at -50°

	103[R3SiK]i	10 <sup>3</sup> [Fluorene] <sub>i</sub>	k mole=1 sec=1	
	mole-1	mole -I		
Ph <sub>3</sub> SiK	4.93	4.08	11.0	
	4.93	7.09	10.9	
	4.93	9.57	11.2	
	4.93	11.10	11.0	
Ph <sub>3</sub> MeSiK	4.79	2.13	36.3	
	4.79	3.46	35.9	
	4.79	5.33	36.5	
4 9 90	4.79	6.52	36.0	
PhMe <sub>2</sub> SiK	3.26	2.06	32.5	
	3.26	3.52	32.7	
	3.26	4.83	32.9	
- Durante	3.26	6.15	32.7	

from the Arrhenius plot were 4.6, 4.3, and 4.5 kcal mole <sup>-1</sup> for Ph<sub>3</sub>SiK, Ph<sub>2</sub>MeSiK and PhMe<sub>2</sub>SiK reactions with folurene in THF, respectively. For this sequence of R<sub>3</sub>SiK the value of A factor calculated for  $-50^{\circ}$  were  $3.7 \times 10^{5}$ ,  $5.9 \times 10^{5}$  and  $8.2 \times 10^{5}$  mole<sup>-1</sup> sec<sup>-1</sup>. The thermodynamic constants of activation calculated for  $-50^{\circ}$ C are given in Table 4. The values quoted have the following estimated systematic errors:k and A factor  $\pm 7\%$ , AH‡ and  $\Delta G\ddagger \pm 5\%$ and  $\Delta S\ddagger \pm 9\%$ . *Products of Reactions*. The product analysis of the reaction between R<sub>3</sub>SiK and fluorene was carried

**Products of Reactions.** The product analysis of the reaction between  $R_3SiK$  and fluorene was carried using the procedure similar to that described for the corresponding reactions of  $R_3SiLi$  with fluorene [1] in THF. The results were in full agreement with the previous findings[1] that only one of the 9-hydrogen atom of fluorene was replaced by the potassium atom of  $R_3SiK$ .

## DISCUSSION

The spectra of R<sub>3</sub>SiK reagents in THF do not give

any significant absorption in the wavelength region above 450 nm even for the highest concentration used in the kinetics experiments (path length 1 mm). Therefore, the rates of reactions between  $R_3SiK$  and fluorene in THF could be most conveniently measured at 470 nm waveleghth, one of the 9-fluorenylpotassium, s (product of reaction) highest absorption peak in the visible region.

Comprison of  $\lambda_{max}$  values of R<sub>3</sub>SiK ( $\lambda_{max}$  363 nm) with the corresponding values of R<sub>3</sub>SiKNa ( $\lambda_{max}$ 338.5±1.5 nm) and R<sub>3</sub>SiLi ( $\lambda_{max}$  335 nm) reveals that a red shift occurs in absorption maximum with the increase in radius of cation. These results are consistent with the results reported for various organometallic compounds [8-14]. 54

Table 3. Tempearature dependence of rate constants.

	Temp.	k l mole-1 sec-1	
Ph <sub>3</sub> SiK	-10	55.0	
	-22	33.9	
		26.7	
	38	18.7	
	45	13.9	
	50	11.0	
Ph-MeSiK		165.5	
2		127.4	
	30	79.3	
	40	56.5	
	50	36.1	
	54	30.3	
PhMeaSiK	-12	141.2	
1		101.2	
		76.2	
	40	51.3	
	50	32.6	
	57	23.5	

Table 4. Thermodynamic constants of activation for the reactions of  $R_3SiK$  with fluorene in THF at  $-50^{\circ}C$ .

		Ph <sub>3</sub> SiK	Ph <sub>3</sub> SiNa	Ph <sub>3</sub> SiLi	Ph2MeSiK	•
k(1 mole <sup>-1</sup> sec	-1)	11.0	5.7	0.3	36-1	
A(1 mole-1 sec-	-1)	3·7×1	05 5·7×10	02 9·2×	105 5·9×105	
$\Delta H_{\pm}^{\pm}$ (kcal mo	ole=1)	4.2	1.6	6.2	3.8	
∆G‡ (kcal mo	le -I)	11.8	12.1	13.5	11.3	
$\triangle S_{+}^{+}$ cal mole	1 deg-1)	<u>-34</u> ·1	-47.2	-32·7	-33.4	
C					7	
Ph2MeSiNa	Ph2MeS	iLi PhM	e2SiK Phl	Me2SiNa	PhMe2SiLi	
13.2	0.8	32	·6	<b></b>	0.8	
1·2×105	6·4×1	06 8	·2×105		3·1·×106	
1.6	6.6	4	·0		6.3	
11.7	13.0	11	•3	•••	13.0	
-45.3		32	·7			
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Note. The values quoted for the corresponding reactions of organosilylsodium and organosilyllithium compounds with flourene in THF, are also calculated for  $-50^{\circ}$ .

In case of 9-fluorenyllithium [1] and 9-fluorenylsodium [2] and  $\epsilon_{\lambda}$  max was found to increase with the decrease in temperature, which has been attributed to the transformation of contact ion-pairs into the solvent separated ion-pairs at reduced temperatures. On the other hand the position of maximum absorptions and the values of  $\epsilon_{\lambda}$ max obtained for the spectra of 9-fluorenylpotassium at reduced temperatures were unaltered. This suggests that 9-fluorenylpotassium continues to exist in the form of contact ion-pairs in THF even at temperature as low as -80° Similar results have been reported by Smid *et al.* [13] in their studies of contact and solvent separated ionpairs of carbanions.

The first order kinetics found for both the reactants and overall second order kinetics for at least 90%of the reaction, together with the results, of product analysis; indicate that the reaction under investigation is as follows.



It is seen from Table 4 that the rate constants for  $R_3SiK$  are greater than those for the corresponding  $R_3SiLi[1]$  and  $R_3SiNa[2]$  reactions with fluorene in THF. This relative increase in the reactivity of  $R_3SiM$  compounds is consistent with the fact that the increase in radius of cation enhances the reactivity of  $R_3SiM$  compounds. A similar pattern of reactivity has also been reported for the reactions of triphenyl-silyl-alkali metal compounds with 1,1'-diphenylethylene [8] in THF and for the anionic polymerization of styrene in dioxane [15-17], while a reverse trend was observed in THF [18-20].

The values of thermodynamic constants of activation for the reactions of  $R_3SiK$  are given in Table 4, together with the corresponding values for the reactions of  $R_3SiLi$  [1] and  $R_3SiNa$  [2] with fluorene in THF, also calculated for  $-50^\circ$ . The sequence for A factor,  $\Delta H^{\ddagger}$  and  $\Delta S^{\ddagger}$  values turns out to be,  $R_3SiNa \angle R_3SiK \angle R_3SiLi$ . The position of  $R_3SiLi$  does not fall in the right sequence. It is known, however, that  $R_3SiLi$  compounds [8] exist as partially solvent separated ion-pairs, whereas the corresponding  $R_3SiNa$  and  $R_3SiK$  exist as contact-ion pairs in THF. These different kind of species could be responsible for the complex behaviour of  $R_3SiM$  compounds.

Comparison of the values of  $\Delta H^{\ddagger}$  for the system involving Na<sup>+</sup> and K<sup>+</sup> cations shows that there is a marked difference in these values. It could be suggested that in R<sub>3</sub>SiNa-fluorene system, the reaction involves better solvation of the transition state rather than the initial state (9-fluorenlysodium exists as solvent separated ion-pairs in THF at reduced temperatures), resulting in lower activation enthalpy for this system. On the other hand the R<sub>3</sub>SiKfluorene system involves equal solvation of both the initial and transition states, and results in relatively higher activation enthalpy.

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